Supporting information

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Table S1. Summary of the electrochemical performance of TMDC/G heterostructures applied in SCs modified by different interfacial strategies.N.A. indicates not available.

Samples	Specific Capacitance	Capacitance Retention	Energy density (Power density)	Ref.
Interfacial doping	nodel			
3D MoS ₂ /NG aerogel	532 F g ⁻¹ (1 A g ⁻¹)	93.6% (10000 cycles at 10 A g ⁻¹)	17.24 Wh kg ⁻¹ (500 W kg ⁻¹)	1
MoS ₂ /NG	146 F g ⁻¹ (20 A g ⁻¹)	91.3% (1000 cycles at 2 A g ⁻¹)	N.A.	2
MoS ₂ /NSG	549.4 F g ⁻¹ (10 mV s ⁻¹)	93.2% (10000 cycles at 20 A g ⁻¹)	65.2 Wh kg ⁻¹ (900 W kg ⁻¹)	3
MoS ₂ /NPG	588 F g ⁻¹ (1 A g ⁻¹)	91.67% (5000 cycles at 3 A g ⁻¹)	24.34 Wh kg ⁻¹ (300 W kg ⁻¹)	4
MoS ₂ -O-G	265 F g ⁻¹ (10 mV s ⁻¹)	92% (1000 cycles)	63 Wh kg ⁻¹	5
Interfacial stacking	model			
MoS ₂ /G superlattice	2483 F g ⁻¹ (10 A g ⁻¹)	92% (8000 cycles at 10 A g ⁻¹)	N.A.	6
MoS ₂ /G superlattice	290 F cm ⁻³ (0.5 A g ⁻¹)	90% (10000 cycles at 0.5 A g ⁻¹)	N.A.	7
Interfacial orientat	ion model			
V-MoS ₂ /rGO fiber	330 F g ⁻¹ (0.1 A g ⁻¹)	95% (10000 cycles, 10 A g ⁻¹)	69.44 μWh cm ⁻² (0.5 mW cm ⁻²)	8
V-MoS ₂ /G	2182.33 mF cm ⁻² (1 mA cm ⁻²)	116.83% (5000 cycles at 10 mA cm ⁻²)	130.34 Wh m ⁻² (4000 W m ⁻²)	9
V-MoS ₂ /G	428 F g ⁻¹ (1 A g ⁻¹)	88% (5000 cycles at 6 A g ⁻¹)	36.5 Wh kg ⁻¹ (9 W kg ⁻¹)	10

Table S2. Summary of the electrochemical performance of TMDC/G heterostructures applied in ZIBs modified by different interfacial strategies.N.A. indicates not available.

Samples	Interlayer of TMDC (nm)	Specific Capacitance	Specific Capacitance	Capacitance Retention	Energy density	Ref.	
Interfacial doping mode	el						
V-MoS ₂ /C	1.02	385 mAh g ⁻¹ (0.1 A g ⁻¹)	230 mAh g ⁻¹ (0.8 A g ⁻¹)	88% (150 cycles at 0.1 A g ⁻¹)	N.A.	11	
Interfacial stacking mod	del						
G/ML-MoS ₂ /G	0.7	202.6 mAh g ⁻¹ (0.1 A g ⁻¹)	104.5 mAh g ⁻¹ (4 A g ⁻¹)	98.6% (600 cycles at 1A g ⁻¹)	148.2Wh kg ⁻¹	12	
hollow MoS ₂ /NC superlattice	0.96	247.8 mAh g ⁻¹ (0.1 A g ⁻¹)	100.9 mAh g ⁻¹ (8 A g ⁻¹)	85.6% (3200 cycles at 1A g ⁻¹)	72.6 Wh kg ⁻¹	13	
MoS ₂ /G superlattice	1.16	285.4 mAh g ⁻¹ (0.05 A g ⁻¹)	141.6 mAh g ⁻¹ (5 A g ⁻¹)	88.2% (1800 cycles at 1A g ⁻¹)	157.5Wh kg ⁻¹	14	
MoS ₂ /PEDOT superlattice	1.29	312.5 mAh g ⁻¹ (0.1 A g ⁻¹)	83.6 mAh g ⁻¹ (15 A g ⁻¹)	90.1% (4000 cycles at 5A g ⁻¹)	184.7Wh kg ⁻¹	15	
MoS ₂ /CTAB superlattice	1	181.8 mAh g ⁻¹ (0.1 A g ⁻¹)	78.5 mAh g ⁻¹ (10 A g ⁻¹)	92.8% (2100 cycles at 10A g ⁻¹)	N.A.	16	
Interfacial orientation model							
V-MoSSe/G	0.64	253.8 mAh g ⁻¹ (0.2 A g ⁻¹)	124.2 mAh g ⁻¹ (5 A g ⁻¹)	83% (1200 cycles at 2A g ⁻¹)	N.A.	17	
V-VS ₂ /G	0.97	238 mAh g ⁻¹ (0.1 A g ⁻¹)	190 mAh g ⁻¹ (5 A g ⁻¹)	93% (1000 cycles at 5A g ⁻¹)	N.A.	18	

Table S3. Summary of the electrochemical performance of TMDC/G heterostructures applied in AMSBs modified by different interfacialstrategies. N.A. indicates not available.

Samples	Sulfur contents & sulfur	Electrochemical performance (initial capacity	Rate	Highest S loading	Voltage window	Ref.
	loading mass	and degradation rate)	Performance		(VS. LI/LI')	
Interfacial doping m	nodel					
Ni-MoS ₂ /rGO	68.4 wt% & 1 mg cm ⁻²	937.8 mAh g ⁻¹ at 0.5 C and	757.2 mAh g ⁻¹ at	5.89 mg cm ⁻²	1.8–2.8 V	19
			20			
MoS ₂ /NG	~80% & 5.2 mg cm ⁻²	772 mAh g^{-1} at 0.2 C and 0.185% for 100 cycles	512 mAh g ⁻¹ at 3C	5.2 mg cm ⁻²	1.7–2.8 V	20
MoSe ₂ /NG		1118 mAb g^{-1} at 0.2 C and	632 mΔh g ⁻¹ at 10		1.8–2.8 V	21
	~62% & 1.1 mg cm ⁻²	0.136% for 100 cycles		/		
	4.2 -2	1063 mAh g ⁻¹ at 0.2 C and	743.2 mAh g ⁻¹ at	10.5 mg cm ⁻²	1.7–2.8 V	22
WSe ₂ /NG	1.2 mg cm ⁻²	0.063% for 300 cycles (1C)	6C			
		~1100 mAh g ⁻¹ at 1 C and	941 mAh g ⁻¹ at 2C	5 07 ²	1.8–2.8 V	23
CO-MOS ₂ /G	1 mg cm ⁻²	0.029% for 1000 cycles		5.27 mg cm ⁻²		
Interfacial stacking model						
	$(20)(8,1,4)(1,0)(1,0)(1,0)(1,0)^{2}$	854 mAh g ⁻¹ at 2 C and	810 mAh g ⁻¹ at 2C	C A	1.7–2.8 V	24
NG/ReS ₂ /NG	63% & 1.4 ° 1.6 mg cm 2	0.064% for 800 cycles		6.4 mg cm ²		
WSe ₂ /G superlattice	72.0	923 mAh g ⁻¹ at 1 C and	569.5 mAh g ⁻¹ at	5 2	1.7–2.8 V	25
	/3.8 WT%	0.0374% for 500 cycles	5C	5.2 mg cm ²		
MoS ₂ /G superlattice	1.02 mg cm ⁻²	1232 mAh g ⁻¹ at 0.2 C and	593 mAh g ⁻¹ at 5C	2.0	1.7–2.8 V	26
		0.08% for 200 cycles		3.8 mg cm -		

Table S3. Summary of the electrochemical performance of TMDC/G heterostructures applied in AMSBs modified by different interfacial strategies. N.A. indicates not available (continued).

Samples	Sulfur contents & sulfur loading mass	Electrochemical performance (initial capacity and degradation rate)	Rate Performance	Highest S loading	Voltage window (vs. Li/Li ⁺)	Ref.
Interfacial orientation	on model					
V-MoS ₂ /G	79.1% & 5.6 mg cm ⁻²	1384 mAh g ⁻¹ at 0.1 C and 0.028% for 500 cycles	530 mAh g ⁻¹ at 5C	5.6 mg cm ⁻²	1.7–2.8 V	27
V-ReS ₂ /G	1 mg cm ⁻²	600 mAh g ⁻¹ at 1 C and 0.0825% for 400 cycles	577 mAh g ⁻¹ at 2C	2.2 mg cm ⁻²	1.7–2.8 V	28
V-MoSSe/G	4.2 mg cm ⁻²	1138 mAh g ⁻¹ at 1C and 0.044% for 1000 cycles	593 mAh g ⁻¹ at 5C	6.5 mg cm ⁻²	1.7–2.8 V	29

Table S4. Summary of the electrochemical performance of TMDC/G heterostructures applied as electrocatalysts modified by different interfacial strategies. N.A. indicates not available.

Samples	Туре	Electrolytes	Overpotential at specific current density	Current density at specific overpotential	Tafel slope	Durability	Ref.
Interfacial d	oping m	odel					
MoS ₂ -Fe-C	OER	6М КОН	155 mV at 10 mA cm ⁻²	N.A.	43 mV dec ⁻¹	120 h	30
MoS ₂ /NSG	OER	1М КОН	360 mV at 10 mA cm ⁻²	N.A.	98.2 mV dec ⁻	10000 cycles	31
MoS ₂ /NG	ORR	0.1M KOH	onset potential +0.95 V	peak potential +0.82 V	N.A.	10000s	32
MoS ₂ /NG	ORR	0.1M KOH	onset potential -0.12 V	peak potential -0.23 V	N.A.	N.A.	33
Interfacial orientation model							
V-ReS ₂ /G	ORR	0.1M KOH	onset potential 0.82 V vs RHE	halt wave potential 0.635 V	76 mV dec ⁻¹	3000 s	34
V-ReS ₂ /NG	ORR	0.1М КОН	N.A.	diffusion-limited current density 5.58 mA cm ⁻²	76 mV dec ⁻¹	3000 s	35
V-MoS ₂ /NC	CO₂RR	0.5 M H ₂ SO ₄	onset potential ~40 mV	34.31 mA cm ⁻² at 590 mV	N.A.	24 h	36

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